

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE



Is Re Patent Application:  
Anguel Nikolov

Serial No.: 10/633,372

Filing Date: August 1, 2003

For: Precision Phase Retardation Devices  
And Method of Making Same

Group Art Unit: 2872

Attorney Docket No.: 02-40171-US

Examiner: Curtis, Craig

**INFORMATION DISCLOSURE STATEMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Applicant submits herewith copies of references or other information of which it is aware that it believes may be material to the examination of this application, and in respect of which, there may be a duty to disclose under 37 C.F.R. § 1.56 and in accordance with 37 C.F.R. §§ 1.97-1.98.

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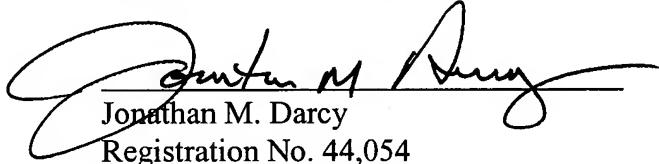
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The Examiner is respectfully requested to review the references identified herewith and make them of record in the instant application as required by M.P.E.P. § 609. The Examiner is also requested to initial one copy of Form 1449 and return same to the undersigned.

Respectfully submitted,



Jonathan M. Darcy

Registration No. 44,054

REED SMITH LLP

2500 One Liberty Place

1650 Market Street

Philadelphia, PA 19103

Telephone: (215) 241-7984

Facsimile: (215) 851-1420

Attorney for Applicant(s)

Enclosures: PTO Form 1449  
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(37 CFR 1.98(b))

ATTY. DOCKET NO. 02-40171-US	10/633,372
APPLICANT Anguel Nikolov et al.	
FILING DATE August 1, 2003	GROUP 2872

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EXAMINER INITIAL	PATENT NUMBER	ISSUE DATE	PATENTEE	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
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